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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/647,000	08/22/2003	Norbert Linder	5367-40	1114
7590 11/29/2004			EXAMINER	
COHEN, PONTANI, LIEBERMAN & PAVANE			THAI, LUAN C	
Suite 1210 555 Fifth Avenu	ue		ART UNIT	PAPER NUMBER
New York, NY			2829	
			DATE MAILED: 11/29/2004	4

Please find below and/or attached an Office communication concerning this application or proceeding.

			V
	Application No.	Applicant(s)	
	10/647,000	LINDER ET AL.	
Office Action Summary	Examiner	Art Unit	
	Luan Thai	2829	
The MAILING DATE of this communication Period for Reply	n appears on the cover sheet w	vith the correspondence address	
A SHORTENED STATUTORY PERIOD FOR RETHER MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CF after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, - If NO period for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by so Any reply received by the Office later than three months after the rearned patent term adjustment. See 37 CFR 1.704(b).	DN. FR 1.136(a). In no event, however, may a n. a reply within the statutory minimum of thi eriod will apply and will expire SIX (6) MO statute, cause the application to become A	reply be timely filed rty (30) days will be considered timely. NTHS from the mailing date of this communicati BANDONED (35 U.S.C. § 133).	ion.
Status			
1) Responsive to communication(s) filed on _	•		
2a) This action is FINAL . 2b) ⊠	This action is non-final.		
3) Since this application is in condition for all	owance except for formal mat	ters, prosecution as to the merits	is
closed in accordance with the practice und	ler <i>Ex parte Quayl</i> e, 1935 C.[D. 11, 453 O.G. 213.	
Disposition of Claims			
4) Claim(s) 1-20 is/are pending in the applica	tion.		
4a) Of the above claim(s) is/are with	drawn from consideration.		
5) Claim(s) is/are allowed.			
6) Claim(s) <u>1,2,11 and 12</u> is/are rejected.			
7) Claim(s) 3-10 and 13-20 is/are objected to		•	
8) Claim(s) are subject to restriction are	nd/or election requirement.		
Application Papers	•		
9) The specification is objected to by the Exar	miner.		
10)⊠ The drawing(s) filed on 22 August 2003 is/a	are: a)⊠ accepted or b)□ ol	ojected to by the Examiner.	
Applicant may not request that any objection to			
Replacement drawing sheet(s) including the co			(d).
11) The oath or declaration is objected to by the	e Examiner. Note the attache	d Office Action or form PTO-152.	
Priority under 35 U.S.C. § 119			
12)⊠ Acknowledgment is made of a claim for fore a)⊠ All b)☐ Some * c)☐ None of:	eign priority under 35 U.S.C.	§ 119(a)-(d) or (f).	
1.⊠ Certified copies of the priority docum	nents have been received.		
2. Certified copies of the priority docum		Application No	4
3. Copies of the certified copies of the			
application from the International Bu			
* See the attached detailed Office action for a		received.	
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Attachment(s)
1) Notice of References Cited (PTO-892)
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date <u>8/22/03</u> .

4) Interview Summary (PTO-413)
Paper No(s)/Mail Date
5) Notice of Informal Patent Application (PTO-152)
a. [7] a.:

6) Other: _____.

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DETAILED ACTION

Claim Objections

1. Claim 20 is objected to because of the following informalities:

In claim 20, the limitation of "the diffusion stop layer (16) is highly-doped" is repeated form, which is claimed, in base claim 19.

Appropriate correction is required.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

 (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 3. Claims 1-2 and 11-12 are rejected under 35 U.S.C. 102(e) as being anticipated by Kuo et al (6,608,328).

The figures and reference numbers referred to in this office action are used merely to indicate an example of a specific teaching and are not to be taken as limiting.

Regarding claims 1-2 and 11-12, Kuo et al (see specifically figures 3-4) disclose a radiation-emitting semiconductor component having a layer structure, comprising: an n-doped cladding layer (321), a p-doped cladding layer (324), an active layer (322) based

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on InGaAlP arranged between the n-doped cladding layer (321) and the p-doped cladding layer (324), and a diffusion stop layer (323) arranged between the active layer (322) and the p-doped cladding layer (324), wherein the active layer comprises a multiple quantum well structure, and wherein the diffusion stop layer (323) is alternately tensile/compressively strained (Col. 9, lines 37+). Kuo et al. further disclose a transparent coupling-out layer (326), which preferably essentially consists of GaP, is arranged on the topmost cladding layer of the layer structure.

Allowable Subject Matter

- 4. Claims 3-10 and 13-20 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 5. The following is a statement of reasons for the indication of allowable subject matter:

The prior art taken either singly or in combination fails to anticipate or fairly suggest: a) the superlattice of the diffusion stop layer having N periods of tensile-strained $In_x(Ga_yAl_{1-y})_{1-x}P$ layers, where 0 < x < 1, 0 < y < 1, and compressively strained $In_x(Ga_yAl_{1-y})_{1-x}P$ layers, where 0 < x < 1, 0 < y < 1, N lying between 2 and 40, preferably between 5 and 20, particularly preferably between 8 and 15, as recited in claim 3; b) the strain lies in the range of 0.1% to 5%, preferably in the range of 0.5% to 2%, particularly preferably in the range of 0.7% to 1%, as recited in claims 5 and 13; c) the p-doped cladding layer being p-doped with magnesium, as recited in claim 6; and d) the diffusion stop layer being highly n-doped, as recited in claim 7; especially when these limitations are considered within the specific combination claimed.

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6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Luan Thai whose telephone number is 571-272-1935. The examiner can normally be reached on 6:45 AM - 4:15 PM, Monday to Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Tokar can be reached on 571-272-1812. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Uhorlinan Luan 7kai

Primary Examiner Art Unit 2829 November 19, 2004